L Number	Hits	Search Text	DB	Time stamp
~	168	kholodenko.in.	USPAT; US-PGPUB;	2004/09/23 11:30
		•	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	13	6478924.pn. or 6464790.pn. or 6464795.pn. or	USPAT	2004/09/24 16:00
		6414834.pn. 6503368.pn. or 6583890.pn. or 6449871.pn. or 6736668.pn. or 6795292.pn. or		
• ]		6572814.pn. or 6490145.pn. or 6689418.pn or		
		6490146.pn. or 6676760.pn. or 6721162.pn		
-	. 10	(6478924.pn. or 6464790.pn. or 6464795.pn. or 6414834.pn. 6503368.pn. or 6583890.pn. or	USPAT	2004/09/28 09:17
		6449871.pn. or 6736668.pn. or 6795292.pn. or		
	-	6572814.pn. or 6490145.pn. or 6689418.pn or		
i		6490146.pn. or 6676760.pn. or 6721162.pn)		
	. 4	and contact	HODAM	2004/20/20 12 00
-	4	"9954920"	USPAT; US-PGPUB;	2004/09/28 12:00
	:		EPO; JPO;	
			DERWENT;	
	,	5500400	IBM_TDB	0001/00/00 00 01
_	2	6599402.pn.	USPAT; US-PGPUB;	2004/09/28 09:34
			EPO; JPO;	
			DERWENT;	
		#1010700#	IBM_TDB	2004/00/00 00 00
-	13	"1010780"	USPAT; US-PGPUB;	2004/09/28 09:36
		)	EPO; JPO;	
		·	DERWENT;	
		6116618	IBM_TDB	0004/00/00 10 00
-	2	6416647.pn.	USPAT; US-PGPUB;	2004/09/28 12:00
		•	EPO; JPO;	
		J	DERWENT;	
		5200506	IBM_TDB	2004/20/20 16 10
_	2	6309526.pn.	USPAT; US-PGPUB;	2004/09/28 16:19
		9	EPO; JPO;	
			DERWENT;	
		6200524 mm	IBM_TDB	2004/09/28 17:18
-	, 2	6309524.pn.	USPAT; US-PGPUB;	2004/09/20 17:10
			EPO; JPO;	
			DERWENT;	
	427		IBM_TDB USPAT;	2004/09/29 17:20
-	431	<pre>"applied materials".as. and ((electro adj chemical) or electrochemical) and contact</pre>	US-PGPUB;	2004/09/28 17:20
			EPO; JPO;	
		*	DERWENT;	
_	31	"applied materials".as. and ((electro adj	<pre>IBM_TDB USPAT;</pre>	2004/09/28 17:51
-	21	chemical) or electrochemical) and (contact	US-PGPUB;	2004/03/20 17:51
		adj pin)	EPO; JPO;	
			DERWENT;	
1_	3	kholodenko.in. and electro-chemical adj	IBM_TDB USPAT;	2004/09/28 17:21
1 -	3	deposition	US-PGPUB;	2004/03/20 17:21
			EPO; JPO;	
			DERWENT;	
_	19	("applied materials" as and ((alectro add	IBM_TDB USPAT;	2004/09/28 17:21
-	. 19	("applied materials".as. and ((electro adj chemical) or electrochemical) and (contact	US-PGPUB;	2004/03/20 1/:21
		adj pin)) not (kholodenko.in. and	EPO; JPO;	
		electro-chemical adj deposition)	DERWENT;	
_	46	   "applied materials".as. and ((electro adj	IBM_TDB USPAT;	2004/09/28 17:52
	40	chemical) or electrochemical) and (contact	US-PGPUB;	2004/09/20 17:32
		adj pad)	EPO; JPO;	
-			DERWENT;	
	<u> </u>		IBM_TDB	

-	35	("applied materials".as. and ((electro adj	USPAT;	2004/09/28 17:52
		chemical) or electrochemical) and (contact	US-PGPUB;	
		adj pad)) not (("applied materials".as. and	EPO; JPO;	
ľ		((electro adj chemical) or electrochemical)	DERWENT;	
		and (contact adj pin)) not (kholodenko.in.	IBM TDB	
		and electro-chemical adj deposition))	_	